

DATA SHEET

FS-Y-343/1~5W

FEMTOSECOND PULSED LASER AT 343nm

Femtosecond pulsed laser at 343nm is made features of short pulse duration, high repetition rate, high average power and good beam quality, which is used in sapphire marking, ceramic cutting, semiconductor cutting, film scribing, physics experiment, etc.









SPECIFICATIONS

Wavelength (nm)	343±5	
Average power (W)	1~5W (5W@1MHz)	
Single pulse energy (µ J)	5(5 µ J @1MHz)	
Rep. rate (MHz)	500kHz~2MHz	
Pulse duration (fs)	<300fs @1MHz,5W.	
Peak power (MW)	17 @1MHz	
Ave power stability (over 4 hours)	<3%	Ship
Warm-up time (minutes)	<10	AVOID EXPOSURE Laser radiation is emitted from this APERTURE
Transverse mode	TEM ₀₀	
Beam quality(M ²)	<1.3	
Beam divergence, full angle (mrad)	<3.0	
Beam diameter at the aperture (1/e ² ,mm)	~1.0	DANGER LASER RADIATION-AVOID EYE SKIN
Polarization ratio	>100:1	EXPOSURE TO DIRECT OR SCATTERED RADIATION
Beam height from base plate (mm)	58	PEAKPOWER<600mW WAVELENGTH 1000-2000nm CLASS IV LASER PRODUCT
Cooled method	Water cooled	This device complies with 21 CFR1040.10 and 1040.11 Changchun New Industries Optoelectronics Tech.Co., Ltd. (CNI) 888 Jinhu Road High-tech Zone Changchun, China
Operating temperature (°C)	15~35	000 SIRBO MOSO TINES-ACID TORK CRISECURE CRISE
Power supply (220/110VAC)	On request	

